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Minimizing scattering from antireflective surfaces replicated from low-aspect-ratio black silicon

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The scattering properties of randomly structured antireflective black silicon polymer replica have been investigated. Using a two-step casting process, the structures can be replicated in Ormocomp on areas of up to 3 in. in diameter. Fourier analysis of scanning electron microscopy images of the structures shows that the scattering properties of the surfaces are related to the spatial periods of the nanostructures. Structures with a dominating spatial period of 160 nm, a height of 200 nm, and aspect ratio of 1.3 show insignificant scattering of light with wavelength above 500 nm and lower the reflectance by a factor of two. © 2012 American Institute of Physics.

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Antireflective nanostructures have the potential to provide an alternative to expensive coatings for optical components. High aspect ratio structures with periods around 200 nm have been shown to greatly reduce Fresnel reflections for a broad band of wavelengths.1 Such periodic structures can be fabricated on large areas by laser interference lithography2 or by anodized aluminium oxide.3 An important feature of this kind of structure is that below a certain ratio between period and wavelength, only zeroth order diffraction will occur at the surface, and no light will be scattered.4,5 Minimizing scattering is crucial when the antireflective element is to remain fully transparent and increase the direct transmission of light. Only recently, the scattering properties due to imperfections in periodic structures have been studied.6

Another method for fabricating antireflective surfaces is by pattern transfer of the nanostructures in black silicon (BSi) surfaces. BSi structures are randomly positioned, cone-shaped formations, formed in silicon by a mask-less etching process.7 However, due to the random nature of these structures, such surfaces will inherently scatter incoming light. Several studies have used this type of structures for antirefection,8–10 but the scattering properties of the surfaces have only recently been addressed.11

In this letter, we present a simple method for replicating BSi structures into Ormocomp, a transparent organic-inorganic hybrid polymer (Micro resist technology Gmbh, Berlin), on areas of up to 3 in. in diameter. The silicon masters were characterized by scanning electron microscopy (SEM) and dark field microscopy, and the Ormocomp replica were characterized by SEM and Fourier analysis, and light transmission measurements. The structures which showed increased transmission for light with a wavelength down to 500 nm were used to demonstrate the antireflective effect, which was significant even for structures with aspect ratio as low as 1.3.

The BSi substrates were structured by reactive ion etching (Pegasus DRIE, STS). The structures were formed in a single etching cycle with an O2/SF6 -based etch.7 By varying the gas-flows and platen power, different types of BSi surfaces were fabricated, denoted from hereon as types A–F.

After etching the BSi substrates [See Fig. 1(a1)], the surface can be patterned using conventional photolithography and dry etching to remove the nanostructures from the defined areas (a2). Using molecular vapor deposition, the BSi masters were coated with an anti-stiction layer. Ormocomp was poured on the master (a3) and a 1.5 mm thick and 4 in. wide polymethyImethacrylate (PMMA) substrate was placed on top. The thickness of the Ormocomp film from the BSi master, while the Ormocomp remained attached to the PMMA back plate. The Ormocomp was cured with UV light in the wavelength range of 260–320 nm, through the PMMA (a4). The type of PMMA is Plexiglas XT 20070, which has a limited but sufficient transmittance in the 260–320 nm range. After UV exposure, the flexibility of the Ormocomp and PMMA allowed for the gradual releasing of the Ormocomp film from the BSi master, while the Ormocomp remained attached to the PMMA (a5). Finally, the Ormocomp Mother stamp was coated with an anti-stiction layer.

Samples with structures on a single face were fabricated by pouring Ormocomp on the Mother stamp and placing a PMMA backplate on top. The Ormocomp was again cured with UV light, through the PMMA, as shown in Figs. 1(b1) and 1(b2). Two identical Ormocomp Mother stamps were used to fabricate samples with identical antireflective structures on the front and back face, see Fig. 1(c). A comparison of the structures on a BSi master and the final Ormocomp sample is shown in Figs. 1(d1) and 1(d2).

The silicon masters and the final Ormocomp samples were characterized by SEM top and side view micrographs. The relative scattering properties of the structures were characterized with a dark field optical microscope (Nikon Eclipse L200). The microscope was calibrated with a highly
scattering sample (type F, see Fig. 2), and the exposure settings and white balance were fixed for all recorded images. Thus, the relative scattering properties of the six types of surfaces can be characterized.

Power spectral densities of each Ormocomp sample were calculated from the top view SEM images by azimuthal averaging of the 2D Fourier spectrum of the surface. This allows for identifying the dominating spatial frequency of the randomly ordered structures.

For the direct transmission measurements, the samples were illuminated at normal incidence with white light (Xenon lamp, HPX-2000, Ocean optics), through a fiber and a collimator. The samples were aligned perpendicular to the incident light using a goniometer. The light was then collected in a fiber with a collimator and analyzed in a spectrometer (Jaz, Ocean Optics). Thus, only non-scattered, directly transmitted light was collected by the collimator.

Angle resolved scattering (ARS) measurements were performed using the same setup, by rotating the collecting fiber around the axis of the illuminated sample. The scattered transmitted light was collected at an angle (θ) from the normal, in the range 15° to 90°.

Figures 2(a) and 2(b) show SEM images of the BSi masters as viewed from the side and top, respectively. Fig. 2(c) shows dark field microscope images of the BSi masters. Fig. 2(d) shows photographs of the fabricated Ormocomp samples, when illuminated by an intense white light source (Xenon lamp). The samples were illuminated at normal incidence and photographed from an oblique angle. The results shown in Figs. 2(c) and 2(d) offer a simple comparison of the relative scattering properties of the different BSi masters and the final Ormocomp samples, respectively.

Figure 3(a1) shows the intensity of transmitted, scattered light, measured at an angle of θ = 30°, for the six different Ormocomp samples. The intensity of the scattered light varies within two orders of magnitude when comparing the different samples. The results show that for all samples, the shorter wavelengths are scattered significantly stronger than the longer wavelengths. Figs. 3(a2) and 3(a3) show surface plots of the full ARS measurements of samples C and A, respectively.

Figure 3(b) shows the power spectral density of a top view SEM image of a type A Ormocomp sample. The black lines show a fit to a power function of the first and last parts of the data. The intersection of the two lines thus marks the dominating spatial frequency, q, of the surface structures, and the error bars represent a 95% confidence interval on q, based on the uncertainties of the parameters of the two fitted functions. Power spectra for the other Ormocomp samples were analyzed in a similar manner, and the intersections are denoted by squares.

Figure 3(c) shows direct transmission measurements of planar and structured Ormocomp samples. For clarity, sample F is not shown as the transmission is below 0.5 throughout the spectrum. Most samples show antireflective properties at a wavelength of 900 nm, while only sample A...
and B show increased transmission down to 500 nm and 550 nm, respectively. Samples C, D, and E show reduced transmission in the entire visible spectrum due to scattering. It is evident that the structures of type A, with aspect ratio of 1.3 and height of 200 nm, reduce the reflectance by a factor of 2, from 4% and down to 2% in the visible spectrum.

The inset in Fig. 3(c) shows the wavelength of the intersection of each transmission line with the planar line, denoted $\lambda_c$, as a function of the dominating structural periods, $q^{-1}$, found in Fig. 3(b). The plot thus correlates the spatial frequency of the surface structures to the scattering properties. This central result shows that larger values of $q$ lower the cut-off wavelength, $\lambda_c$, at which scattering becomes significant.

This shows that replica of BSi structures are viable for increasing transmission of light in the visible spectrum, despite the random nature on the structures. Furthermore, the scattering properties can be estimated simply from a top view SEM image.

Finally, the type A structures were used to fabricate a sample with nanostructures on both faces, see Fig. 1(c). The resulting sample is shown in Fig. 4(a), where the transparent Ormocomp disc is placed on a sheet of paper with a printed logo. On the left side, the light from a lamp is reflected specularly from the planar top and bottom surface of the sample. On the right side, nanostructures covering both the top and the bottom faces suppress part of the Fresnel reflections, rendering the underlying surface visible. We note that the scattered blue light is too dim to see in daylight conditions.

In conclusion, we have shown that the spatial frequencies of BSi structures are related to the scattering properties of the antireflective surfaces. Structures with a dominating spatial frequency of 160 nm, a height of 200 nm, and aspect ratio of 1.3 show insignificant scattering of light with wavelengths above 500 nm and reduce Fresnel reflections by up to a factor of 2. Using a simple two-step casting process, the structures can be fabricated in Ormocomp on areas of up to 3 in. in diameter.

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